



IFW

**PATENT APPLICATION
IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re application of

Docket No: Q80755

Kesahiro KOIKE

Appln. No.: 10/809,523

Group Art Unit: 1765

Confirmation No.: 7526

Examiner: Lan Vinh

Filed: March 26, 2004

For: METHOD OF PRODUCING A GLASS SUBSTRATE FOR A MASK BLANK AND
METHOD OF PRODUCING A MASK BLANK

PETITION FOR EXTENSION OF TIME UNDER 37 C.F.R. § 1.136

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Pursuant to 37 C.F.R. § 1.136, Applicant hereby petitions for an extension of time of two month(s), extending the time for responding to the Office Action of February 2, 2006 to July 2, 2006.

A check for the statutory fee of \$450.00 is attached. The USPTO is directed and authorized to charge all required fees, except for the Issue Fee and the Publication Fee, to Deposit Account No. 19-4880. Please also credit any overpayments to said Deposit Account. A duplicate copy of this sheet is enclosed.

Respectfully submitted,

Alan J. Kasper
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WASHINGTON OFFICE

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Date: June 29, 2006